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## **Supporting Information**

## Direct Synthesis of Flexible Graphene Glass with Macroscopic Uniformity Enabled by Copper-Foam-Assisted PECVD

Nan Wei<sup>a†</sup>, Qiucheng Li<sup>a,b†</sup>, Shan Cong<sup>a†</sup>, Haina Ci<sup>b</sup>, Yingze Song<sup>a</sup>, Qifeng Yang<sup>a</sup>, Chen Lu<sup>a</sup>, Chao Li<sup>a</sup>, Guifu Zou<sup>a</sup>, Jingyu Sun<sup>a\*</sup>, Yanfeng Zhang<sup>b\*</sup>, and Zhongfan Liu<sup>a,b\*</sup>

<sup>a</sup>College of Energy, Soochow Institute for Energy and Materials InnovationS (SIEMIS), Key Laboratory of Advanced Carbon Materials and Wearable Energy Technologies of Jiangsu Province, Soochow University, Suzhou 215006, P. R. China

<sup>b</sup>Center for Nanochemistry (CNC), Beijing National Laboratory for Molecular Sciences, College of Chemistry and Molecular Engineering, Peking University, Beijing 100871, P. R. China

<sup>†</sup>These authors contributed equally to this work.

\*Corresponding authors: <u>sunjy86@suda.edu.cn</u> (J. Sun); <u>yanfengzhang@pku.edu.cn</u> (Y. Zhang); <u>zfliu@pku.edu.cn</u> (Z. Liu).



**Figure S1**. Photograph of the pristine flexible substrates (from left to right): flexible glass, mica sheet, glass fiber cloth.

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**Figure S2.** Photograph of typical copper-foam-cage and nickel-foam-cage with the size of 4 cm (length)  $\times$  2 cm (width)  $\times$  1 cm (height).



**Figure S3.** XPS Cu 2p spectrum of as-produced graphene glass after copper-foam-assisted PECVD reaction, showing the absence of Cu species.



Before growth

After growth

**Figure S4.** Photograph showing the flexible glass substrate (left) and flexible graphene glass (right). The growth condition was: 550 °C; 100 sccm Ar, 30 sccm H<sub>2</sub>, 10 sccm CH<sub>4</sub>; 80 W for 60 min.



**Figure S5.** (a) Photograph of the as-grown flexible graphene glass (lower sample) exhibiting good uniformity as compared to bare substrate (upper sample). (b) Photograph of as-grown flexible graphene glass samples (1 cm  $\times$  5 cm) obtained at a growth temperature of 500 °C, 550 °C, and 600 °C, respectively (Growth condition: Ar:H<sub>2</sub>:CH<sub>4</sub> at a flow rate of 100:30:10 sccm, growth duration of 60 min, radio frequency at 80 W).



**Figure S6.** Raman spectra of graphene directly grown on mica and flexible glass substrates under different growth temperatures.



Nickel-foam-assisted



Copper-foam-assisted

**Figure S7.** SEM images of directly-grown graphene *via* nickel-foam-assisted (left panel) and copperfoam-assisted (right panel) PECVD approach. Note that the other growth parameters were kept identical (650 °C; 100 sccm Ar, 30 sccm H<sub>2</sub>, 10 sccm CH<sub>4</sub>; 80 W for 60 min).



**Figure S8.** SEM images of directly-grown graphene *via* copper-foam-assisted PECVD at different growth durations (60 min for left panel and 120 min for right panel). Note that the other growth parameters were kept identical (650 °C; 100 sccm Ar, 30 sccm H<sub>2</sub>, 10 sccm CH<sub>4</sub>; 80 W).



**Figure S9.** Photograph of mica-based graphene glass grown via PECVD without (left column) and with (right column) the copper foam assistance. The growth conditions for each row were kept identical (700 °C; 100 sccm Ar, 30 sccm H<sub>2</sub>, 10 sccm CH<sub>4</sub>; growth duration of 60 min, 120 min, and 180 min).

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Figure S10. Surface temperature mapping of flexible graphene glass (10 cm  $\times$  10 cm) upon light exposure for 100 s.



**Figure S11.** Direct integration of as-produced flexible graphene glass as a conductive electrode (flat state) toward lighting up the LED indicator.



Figure S12. Schematic set-up of PECVD apparatus for the growth of N-doped graphene glass.



**Figure S13.** Photograph of as-grown N-doped graphene glass samples  $(3.0 \text{ cm} \times 1.5 \text{ cm})$  obtained for growth time of 60 min and 120 min with a bare flexible glass substrate (leftmost) shown for comparison.



**Figure S14.** (a) Photograph of the pure flexible glass fiber cloth (left), graphene glass fiber cloth (center), and N-doped graphene glass fiber. (b) Photograph of as-grown flexible graphene glass fiber cloth samples obtained from different growth durations, with a bare glass fiber cloth (leftmost) displayed for comparison.



**Figure S15.** Representative Raman spectra obtained from flexible N-doped glass fiber cloth samples grown at 500 °C, 550 °C, and 580 °C, respectively.



**Figure S16.** Spatial distribution of the sheet resistance of graphene and N-doped graphene film grown on flexible glass fiber cloth substrates.

**Table S1.** Comparison of synthetic routes and other information for graphene glass reported between this work and other studies.

Authors	Synthetic routes	Tr% (at 550 nm)	<i>R</i> s (Ω sq <sup>-1</sup> )	Growth temperature (°C)	Ref.
J. Sun et al.	CVD	82%	370-510	1050	ACS Nano 2016, 10, 11136
J. Sun et al.	CVD	81%	1750-2350	1050	Nano Lett. 2015, 15, 5846.
J. Sun et al.	PECVD	84.6%	5200	600	Nano Res. 2015, 8, 3496.
X. Chen et al.	Ethanol- based CVD	83.5%	1300	1100-1200	Adv. Mater. <b>2017</b> , 29, 1603428.
H. Ci et al.	PECVD	82.9%	10900	580	Nano Res. 2018, 11, 3106
Y. Qi et al.	PECVD	81.9%	4100	580	Adv. Mater. 2018, 1704839
N. Wei et al.	Cu-foam- assisted PECVD	85.7%	3600	650	This work